

PATENT APPLICATION

HISTORY

1-22-03

Group Art Unit: 2815

J. Jackso

36654.04

Examiner:

Docket No.:

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Mitsutoshi MIYASAKA

Application No.: 09/885,027

Filed: June 21, 2001

THE THIN FILM SEMICONDUCTOR DEVICE ITSELF, LIQUID CRYSTAL

DISPLAY, AND ELECTRONIC DEVICE

AMENDMENT UNDER 37 C.F.R. §1.111

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

Sir:

For:

In reply to the August 20, 2002 Office Action, the period for reply extended to January 21, 2003, by a Petition for Extension Time, filed herewith, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claims 1 and 2 as follows:

1. (Amended) A thin film semiconductor device, comprising:

a substrate;

an underlevel protection layer formed over the substrate and including a

plurality of films, at least one of which includes a silicon oxide; and

a crystallized semiconductor layer in contact with the film including the silicon oxide, wherein the crystallized semiconductor layer forms an active layer of a transistor,

an effective doping concentration of the crystallized semiconductor layer figuring 1×10^{18} cm⁻³ or less and the crystallized semiconductor layer having the thickness of